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Bipolar P-N-P Transistors Level 503

1.1 Introduction

In this chapter the Mextram 503 models are described as the p channel model and the p channel substrate model. The models provide a detailed description of a vertical integrated circuit PNP transistor. It is meant to be used for DC, transient and AC analyses at all current levels, i.e. high and low injection, quasi and hard saturation. In comparison with the p channel Mextram 502 model, the description of the collector region is improved. The base-collector depletion charge and the reverse current I_R now depend on the same internal base-collector voltage V_{B2C2} . The modeling of the epilayer resistance is rewritten and takes into account current spreading. All this results in a more accurate modeling of the collector transit time. Other parts of the models are rewritten to obtain better convergency behaviour. For **Pstar** and **Spectre** users they are available as built-in model.

The p channel Mextram 503 model and the p channel substrate Mextram 503 model are almost identical. In case of a difference between the models, it is mentioned explicitly that the information given is only relevant for the p channel Mextram 503 model or the p channel substrate Mextram 503 model.

1.2 Simulator specific items

1.2.1 Pstar syntax

```
p channel model          :      tp_n      (c, b, e)  level=503, <parameters>
p channel substrate model :      tps_n     (c, b, e, s) level=503, <parameters>
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n                       :      occurrence indicator
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```
<parameters>          :      list of model parameters
```

c, b, e and s are collector, base, emitter and substrate terminals respectively.

1.3 Survey of modeled effects

- Temperature effects
- Charge storage effects
- Substrate effects and parasitic pnp (for the TPS device only)
- High-injection effects
- Built-in electric field in base region
- Bias-dependent Early effect
- Low-level non-ideal base currents
- Hard and quasi-saturation
- Weak avalanche
- Hot carrier effects in the collector epilayer
- Explicit modeling of inactive regions
- Split base-collector depletion capacitance
- Current crowding and conductivity modulation for base resistance
- First order approximation of distributed high frequency effects in the intrinsic base (high frequency current crowding and excess phase shift).

1.4 Parameters

The parameters for the TPS-level-503 are listed below.

Position in list		Parameter name	Units	Description
TN	TNS			
1	1	<i>LEVEL</i>	-	Model level, must be set to 503
2	2	<i>MULT</i>	-	Multiplication factor
3	3	<i>TREF</i>	°C	Reference temperature
4	4	<i>DTA</i>	K	Difference of the device temperature to the ambient temperature ($T_{DEVICE} = T_{AMBIENT} + DTA$)
5	5	<i>EXMOD</i>	-	Flag for extended modeling of the reverse current gain (default is .false. =0 and .true. =1)
6	6	<i>EXPHI</i>	-	Flag for distributed high frequency effects in transient (default is .false. =0 and .true. =1)
7	7	<i>EXAVL</i>	-	Flag for extended modeling of avalanche currents (default is .false. =0 and .true. =1)
8	8	<i>IS</i>	A	Collector-emitter saturation current
9	9	<i>BF</i>	-	Ideal forward current gain
10	10	<i>XIBI</i>	-	Fraction of ideal base current that belongs to the sidewall
11	11	<i>IBF</i>	A	Saturation current of the non-ideal forward base current
12	12	<i>VLF</i>	V	Cross-over voltage of the non-ideal forward base current
13	13	<i>IK</i>	A	High-injection knee current
14	14	<i>BRI</i>	-	Ideal reverse current gain
15	15	<i>IBR</i>	A	Saturation current of the non-ideal reverse base current
16	16	<i>VLR</i>	V	Cross-over voltage of the non-ideal reverse base current
17	17	<i>XEXT</i>	-	Part of I_{EX} , Q_{EX} , Q_{TEX} and I_{SUB} that depends on the base-collector voltage V_{BC1}
18	18	<i>QBO</i>	C	Base charge at zero bias

Position in list		Parameter name	Units	Description
TN	TNS			
19	19	<i>ETA</i>	-	Factor of the built-in field of the base (= η)
20	20	<i>AVL</i>	-	Weak avalanche parameter
21	21	<i>EFI</i>	-	Electric field intercept (with <i>EXAVL</i> =1).
22	22	<i>IHC</i>	A	Critical current for hot carriers
23	23	<i>RCC</i>	Ω	Constant part of the collector resistance
24	24	<i>RCV</i>	Ω	Resistance of the unmodulated epilayer
25	25	<i>SCRCV</i>	Ω	Space charge resistance of the epilayer
26	26	<i>SFH</i>	-	Current spreading factor epilayer
27	27	<i>RBC</i>	Ω	Constant part of the base resistance
28	28	<i>RBV</i>	Ω	Variable part of the base resistance at zero bias
29	29	<i>RE</i>	Ω	Emitter series resistance
30	30	<i>TAUNE</i>	s	Minimum delay time of neutral and emitter charge
31	31	<i>MTAU</i>	-	Non-ideality factor of the neutral and emitter charge
32	32	<i>CJE</i>	F	Zero bias collector-base depletion capacitance
33	33	<i>VDE</i>	V	Emitter-base diffusion voltage
34	34	<i>PE</i>	-	Emitter-base grading coefficient
35	35	<i>XCJE</i>	-	fraction of the emitter-base depletion capacitance that belongs to the sidewall
36	36	<i>CJC</i>	F	Zero bias collector-base depletion capacitance
37	37	<i>VDC</i>	V	Collector-base diffusion voltage
38	38	<i>PC</i>	-	Collector-base grading coefficient variable part
39	39	<i>XP</i>	-	Constant part of of <i>CJC</i>
40	40	<i>MC</i>	-	Collector current modulation coefficient
41	41	<i>XCJC</i>	-	fraction of the collector-base depletion capacitance under the emitter area
42	42	<i>VGE</i>	V	Band-gap voltage of the emitter
43	43	<i>VGB</i>	V	Band-gap voltage of the base
44	44	<i>VGC</i>	V	Band-gap voltage of the collector
45	45	<i>VGJ</i>	V	Band-gap voltage recombination emitter-base junction

Position in list		Parameter name	Units	Description
TN	TNS			
46	46	<i>VI</i>	V	Ionization voltage base dope
47	47	<i>NA</i>	cm ⁻³	Maximum base dope concentration
48	48	<i>ER</i>	-	Temperature coefficient of <i>VLF</i> and <i>VLR</i>
49	49	<i>AB</i>	-	Temperature coefficient resistivity base
50	50	<i>AEPI</i>	-	Temperature coefficient resistivity of the epilayer
51	51	<i>AEX</i>	-	Temperature coefficient resistivity of the extrinsic base
52	52	<i>AC</i>	-	Temperature coefficient resistivity of the buried layer
53	53	<i>KF</i>	-	Flickernoise coefficient ideal base current
54	54	<i>KFN</i>	-	Flickernoise coefficient non-ideal base current
55	55	<i>AF</i>	-	Flickernoise exponent
*	56	<i>ISS</i>	A	base-substrate saturation current
*	57	<i>IKS</i>	A	Knee current of the substrate
*	58	<i>CJS</i>	F	Zero bias collector-substrate depletion capacitance
*	59	<i>VDS</i>	V	Collector-substrate diffusion voltage
*	60	<i>PS</i>	-	Collector-substrate grading coefficient
*	61	<i>VGS</i>	V	Band-gap voltage of the substrate
*	62	<i>AS</i>	-	For a closed buried layer: <i>AS=AC</i> For an open buried layer: <i>AS=AEPI</i>

3 Note

The parameters marked by * are not valid for the TP-level-503 model.

Parameter *MULT*

This parameter may be used to put several transistors in parallel. To scale the geometry of a transistor use of the process-block is preferable over using this feature.

The following parameters are multiplied by *MULT*:

The TP device: *IS IK IBF IBR QBO IHC CJE CJC*

The TPS device: *IS IK IBF IBR ISS IKS QBO IHC CJE CJC CJS*

Divided by *MULT* are:

RCC SCRCV RCV RBC RBV RE

Default and clipping values

The default values and clipping values for the TP/TPS-level-503 are listed below (The parameters marked by * are not valid for the TP-level-503 model).

No.	Parameter	Units	Default	Clip low	Clip high
1	<i>LEVEL</i>	-	503	-	-
2	<i>MULT</i>	-	1.00	0.0	-
3	<i>TREF</i>	°C	25.00	-273.15	-
4	<i>DTA</i>	K	0.00	-	-
5	<i>EXMOD</i>	-	1.00	0.0	1.0
6	<i>EXPHI</i>	-	0.00	0.0	1.0
7	<i>EXAVL</i>	-	0.00	0.0	1.0
8	<i>IS</i>	A	5.00×10^{-17}	0.0	-
9	<i>BF</i>	-	140.00	1.0×10^{-4}	-
10	<i>XIBI</i>	-	0.00	0.0	1.0
11	<i>IBF</i>	A	2.00×10^{-14}	0.0	-
12	<i>VLF</i>	V	0.50	-	-
13	<i>IK</i>	A	15.00×10^{-3}	1.0×10^{-12}	-
14	<i>BRI</i>	-	16.00	1.0×10^{-4}	-
15	<i>IBR</i>	A	8.00×10^{-15}	0.0	-
16	<i>VLR</i>	V	0.50	-	-
17	<i>XEXT</i>	-	0.50	0.0	1.0
18	<i>QBO</i>	C	1.20×10^{-12}	1.0×10^{-18}	-
19	<i>ETA</i>	-	4.00	0.0	-
20	<i>AVL</i>	-	50.00	0.1	-
21	<i>EFI</i>	-	0.70	0.0	-
22	<i>IHC</i>	A	3.00×10^{-3}	1.0×10^{-12}	-
23	<i>RCC</i>	Ω	25.00	1.0×10^{-6}	-
24	<i>RCV</i>	Ω	750.00	1.0×10^{-6}	-
25	<i>SCRCV</i>	Ω	1000.00	1.0×10^{-6}	-

No.	Parameter	Units	Default	Clip low	Clip high
26	<i>SFH</i>	-	0.60	0.0	-
27	<i>RBC</i>	Ω	50.00	1.0×10^{-6}	-
28	<i>RBV</i>	Ω	100.00	1.0×10^{-6}	-
29	<i>RE</i>	Ω	2.00	1.0×10^{-6}	-
30	<i>TAUNE</i>	s	3.00×10^{-10}	0.0	-
31	<i>MTAU</i>	-	1.18	1.0	2.0
32	<i>CJE</i>	F	2.50×10^{-13}	1.0×10^{-21}	-
33	<i>VDE</i>	V	0.90	0.05	-
34	<i>PE</i>	-	0.33	0.01	0.99
35	<i>XCJE</i>	-	0.50	0.0	1.0
36	<i>CJC</i>	F	1.30×10^{-13}	1.0×10^{-21}	-
37	<i>VDC</i>	V	0.60	0.05	-
38	<i>PC</i>	-	0.40	0.01	0.99
39	<i>XP</i>	-	0.20	0.0	1.0
40	<i>MC</i>	-	0.50	0.0	1.0
41	<i>XCJC</i>	-	0.10	0.0	0.999
42	<i>VGE</i>	V	1.01	0.1	-
43	<i>VGB</i>	V	1.18	0.1	-
44	<i>VGC</i>	V	1.205	0.1	-
45	<i>VGJ</i>	V	1.10	0.1	-
46	<i>VI</i>	V	0.04	0.0	-
47	<i>NA</i>	cm^{-3}	3.00×10^{17}	1.0×10^2	-
48	<i>ER</i>	-	2.00×10^{-3}	-	-
49	<i>AB</i>	-	1.35	-	-
50	<i>AEPI</i>	-	2.15	-	-
51	<i>AEX</i>	-	1.00	-	-
52	<i>AC</i>	-	0.40	-	-
53	<i>KF</i>	-	2.00×10^{-16}	0.0	-
54	<i>KFN</i>	-	2.00×10^{-16}	0.0	-

No.	Parameter	Units	Default	Clip low	Clip high
55	<i>AF</i>	-	1.00	0.01	-
56*	<i>ISS</i>	A	6.00×10^{-16}	0.0	-
57*	<i>IKS</i>	A	5.00×10^{-6}	1.0×10^{-12}	-
58*	<i>CJS</i>	F	1.00×10^{-12}	0.0	-
59*	<i>VDS</i>	V	0.50	0.05	-
60*	<i>PS</i>	-	0.33	0.01	0.99
61*	<i>VGS</i>	V	1.15	0.1	-
62*	<i>AS</i>	-	2.15	-	-

1.5 Pstar specific items

1.5.1 The ON/OFF condition

The solution of a circuit involves a process of successive calculations. The calculations are started from a set of 'initial guesses' for the electrical quantities of the nonlinear elements. A simplified DCAPPROX mechanism for devices using ON/OFF keywords is mentioned in [56]. By default the devices start in the default state.

TP level 503			
	Default	ON	OFF
V_{BC1}	1.0	0.0	1.0
V_{B1C1}	1.0	0.0	1.0
V_{B2C1}	1.0	0.0	1.0
V_{B2C2}	1.0	0.0	1.0
V_{B1E1}	-0.65	-0.75	0.3
V_{B2E1}	-0.65	-0.75	0.3
V_{B1B2}	-1.0×10^{-6}	-1.0×10^{-6}	0.0

TPS level 503			
	Default	ON	OFF
V_{BC1}	1.0	0.0	1.0
V_{B1C1}	1.0	0.0	1.0
V_{B2C1}	1.0	0.0	1.0
V_{B2C2}	1.0	0.0	1.0
V_{B1E1}	-0.65	-0.75	0.3
V_{B2E1}	-0.65	-0.75	0.3
V_{B1B2}	-1.0×10^{-6}	-1.0×10^{-6}	0.0
V_{SC1}	5.0	5.0	5.0

1.5.2 Numerical adaptation

To implement the model in a circuit simulator, care must be taken of the numerical stability of the simulation program. A small non-physical conductance, G_{min} , is connected between the nodes $B1C1$ and $B2E1$. The value of the conductance is 10^{-13} [1/ Ω].

1.5.3 DC operating point output

The DC operating point output facility gives information on the state of a device at its operation point.

$$\begin{aligned}
 dI_n &= g_x \cdot dV_{E1B2} + g_y \cdot dV_{C2B2} + g_z \cdot dV_{C1B2} \\
 dI_{C2C1} &= grcv_y \cdot dV_{C2B2} + grcv_z \cdot dV_{C1B2} \\
 dI_{EB} &= j\omega \cdot (Cbe_y \cdot dV_{C2B2} + Cbe_z \cdot dV_{C1B2}) \\
 dI_{CB} &= g_{\mu x} \cdot dV_{E1B2} + g_{\mu z} \cdot dV_{C1B2} + j\omega \cdot (Cbc_x \cdot dV_{E1B2} + Cbc_z \cdot dV_{C1B2}) \\
 dI_{B2B1} &= grbv_x \cdot dV_{E1B2} + grbv_y \cdot dV_{C2B2} + grbv_z \cdot dV_{C1B2} + j\omega \cdot C_{B2x B1} \cdot dV_{E1B2} \\
 dSI_{EB} &= j\omega \cdot SC_{TE} \cdot dV_{E1B2}
 \end{aligned}$$

For the TPS device:

$$dI_{SUB} = g_{NPN} \cdot dV_{C1B1} + Xg_{NPN} \cdot dV_{C1B}$$

Quantity	Equation	Description
<i>LEVEL</i>	503	Model level
<i>RE</i>	<i>RE</i>	Emitter resistance
<i>RCC</i>	<i>RCC</i>	Constant part of the collector resistance
<i>RBC</i>	<i>RBC</i>	Constant part of the base resistance
<i>RBV</i>	<i>rbv</i>	Variable part of the base resistance: $1/(\partial I_{B1B2}/\partial V_{B1B2})$
<i>GPI</i>	g_π	Conductance floor b-e junction: $\partial I_{B1}/\partial V_{E1B2} + \partial I_{B2}/\partial V_{E1B2}$
<i>SGPI</i>	Sg_π	Conductance sidewall e-b junction: $\partial I_{B1}^S/\partial V_{E1B1}$

For the TP device:

<i>GMUEX</i>	$g_{\mu EX}$	Conductance floor extrinsic c-b junction: $\partial(I_{EX} + I_{B3})/\partial V_{C1B1}$
<i>XGMUEX</i>	$Xg_{\mu EX}$	Conductance sidewall extrinsic c-b junction: $\partial XI_{EX}/\partial V_{C1B}$

For the TPS device:

$$GMUEX \quad g_{\mu EX} \quad \partial(I_{EX} + I_{B3} + I_{SUB})/\partial V_{C1B1}$$

$$XGMUEX \quad Xg_{\mu EX} \quad \partial(XI_{EX} + XI_{SUB})/\partial V_{C1B}$$

$$CBEX \quad Cbe_X \quad \text{Capacitance floor e-b junction:} \\ \partial Q_{TE}/\partial V_{E1B2} + \partial Q_{BE}/\partial V_{E1B2} + \partial Q_N/\partial V_{E1B2}$$

$$CBCY \quad Cbc_Y \quad \text{Capacitance intrinsic c-b junction:} \\ \partial Q_{TC}/\partial V_{C2B2} + \partial Q_{CB}/\partial V_{C2B2} + \partial Q_{EPI}/\partial V_{C2B2}$$

$$CBCEX \quad Cbc_{EX} \quad \text{Capacitance floor extrinsic c-b junction:} \\ \partial Q_{TEX}/\partial V_{C1B1} + \partial Q_{EX}/\partial V_{C1B1}$$

$$XCBCEX \quad XCbc_{EX} \quad \text{Capacitance sidewall extrinsic c-b junction:} \\ \partial XQ_{TEX}/\partial V_{C1B1} + \partial XQ_{EX}/\partial V_{C1B}$$

$$CB1B2 \quad C_{B2B1} \quad \text{Capacitance AC current crowding: } \partial Q_{B2B1}/\partial V_{B2B1}$$

$$GX \quad g_x \quad \text{Forward transconductance: } \partial I_N/\partial V_{E1B2}$$

$$GY \quad g_y \quad \text{Reverse transconductance: } \partial I_N/\partial V_{C2B2}$$

$$GZ \quad g_z \quad \text{Collector Early-effect on } I_N : \partial I_N/\partial V_{C1B2}$$

$$GRCVX \quad grcv_x \quad \text{Obsolete! } \partial I_{C1C2}/\partial V_{E1B2}$$

$$GRCVY \quad grcv_y \quad \text{Conductance with respect to external voltage:} \\ \partial I_{C2C1}/\partial V_{C2B2}$$

$$GRCVZ \quad grcv_z \quad \text{Conductance with respect to external voltage:} \\ \partial I_{C2C1}/\partial V_{C1B2}$$

$$CBEY \quad Cbe_Y \quad \text{Internal collector Early-effect on } Q_{BE} : \partial Q_{BE}/\partial V_{C2B2} \\ \text{(includes repartitioning for EXPHI)}$$

$$CBEZ \quad Cbe_Z \quad \text{External collector Early-effect on } Q_{BE} : \partial Q_{BE}/\partial V_{C1B2} \\ \text{(includes repartitioning for EXPHI)}$$

$$GMU \quad g_{\mu} \quad \text{Dependence avalanche multiplication on internal c-b} \\ \text{junction: } -\partial I_{AVL}/\partial V_{C2B2}$$

$$GMUX \quad g_{\mu X} \quad \text{Dependence avalanche multiplication on internal e-b} \\ \text{junction: } -\partial I_{AVL}/\partial V_{E1B2}$$

<i>GMUZ</i>	$g_{\mu Z}$	Dependence avalanche multiplication on external c-b junction: $-\partial I_{AVL}/\partial V_{C1B2}$
<i>CBCX</i>	Cbc_X	Emitter Early-effect on Q_{BC} : $\partial Q_{CB}/\partial V_{E1B2}$
<i>CBCZ</i>	Cbc_Z	Collector Early-effect on Q_{TC} , Q_{BC} and Q_{EPI} : $\partial Q_{TC}/\partial V_{C1B2} + \partial V_{CB}/\partial V_{C1B2} + \partial Q_{EPI}/\partial V_{C1B2}$
<i>GRBVX</i>	$grbv_X$	Emitter Early-effect on I_{B2B1} : $\partial I_{B2B1}/\partial V_{E1B2}$
<i>GRBVY</i>	$grbv_Y$	Internal collector Early-effect on I_{B2B1} : $\partial I_{B2B1}/\partial V_{C2B2}$
<i>GRBVZ</i>	$grbv_Z$	External Early-effect on I_{B2B1} : $\partial I_{B2B1}/\partial V_{C1B2}$
<i>CB2B1X</i>	C_{B2B1X}	Dependence of Q_{B2B1} on internal e-b junction voltage: $\partial Q_{B2B1}/\partial V_{E1B2}$
<i>SCTE</i>	SC_{TE}	Dependence of Q_{TE}^S on internal e-b junction voltage: $\partial Q_{TE}^S/\partial V_{E1B2}$

For the TPS device:

Quantity Equation

<i>GSUB</i>	g_{sub}	Conductance c-s junction: $\partial I_{SF}/\partial V_{C1S}$
<i>CTS</i>	C_{TS}	Capacitance c-s junction: $\partial Q_{TS}/\partial V_{C1S}$
<i>GNPN</i>	g_{NPN}	Transconductance floor extrinsic NPN transistor: $\partial I_{SUB}/\partial V_{C1B1}$
<i>XGNPN</i>	Xg_{NPN}	Transconductance sidewall extrinsic NPN transistor: $\partial XI_{SUB}/\partial V_{C1B}$

Remark: The operating-point output will not be influenced by the value of G_{min} .

1.6 Equivalent circuit and equations

A full description of TP/TPS-level-503 for vertical integrated circuit NPN transistor is given below. The equivalent circuits for the TP-level-503 model are shown in Figures 1 and 3 respectively. The equivalent circuits for the TPS-level-503 model are shown in figures 2 and 3 respectively.

3 Note

The elements in the figure indicates their position and NOT their functional dependence!

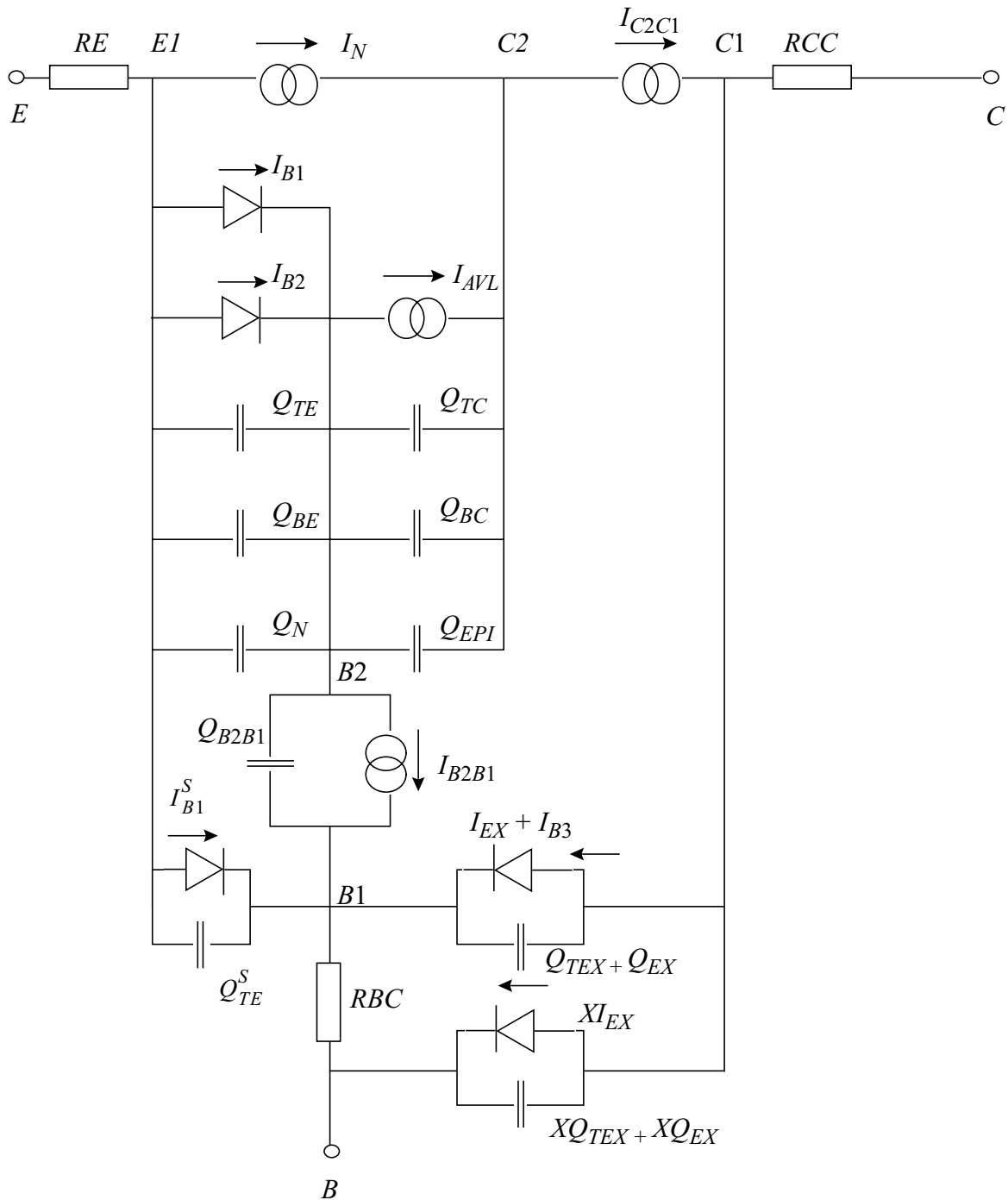


Figure 1: Equivalent circuit for TP PNP transistor

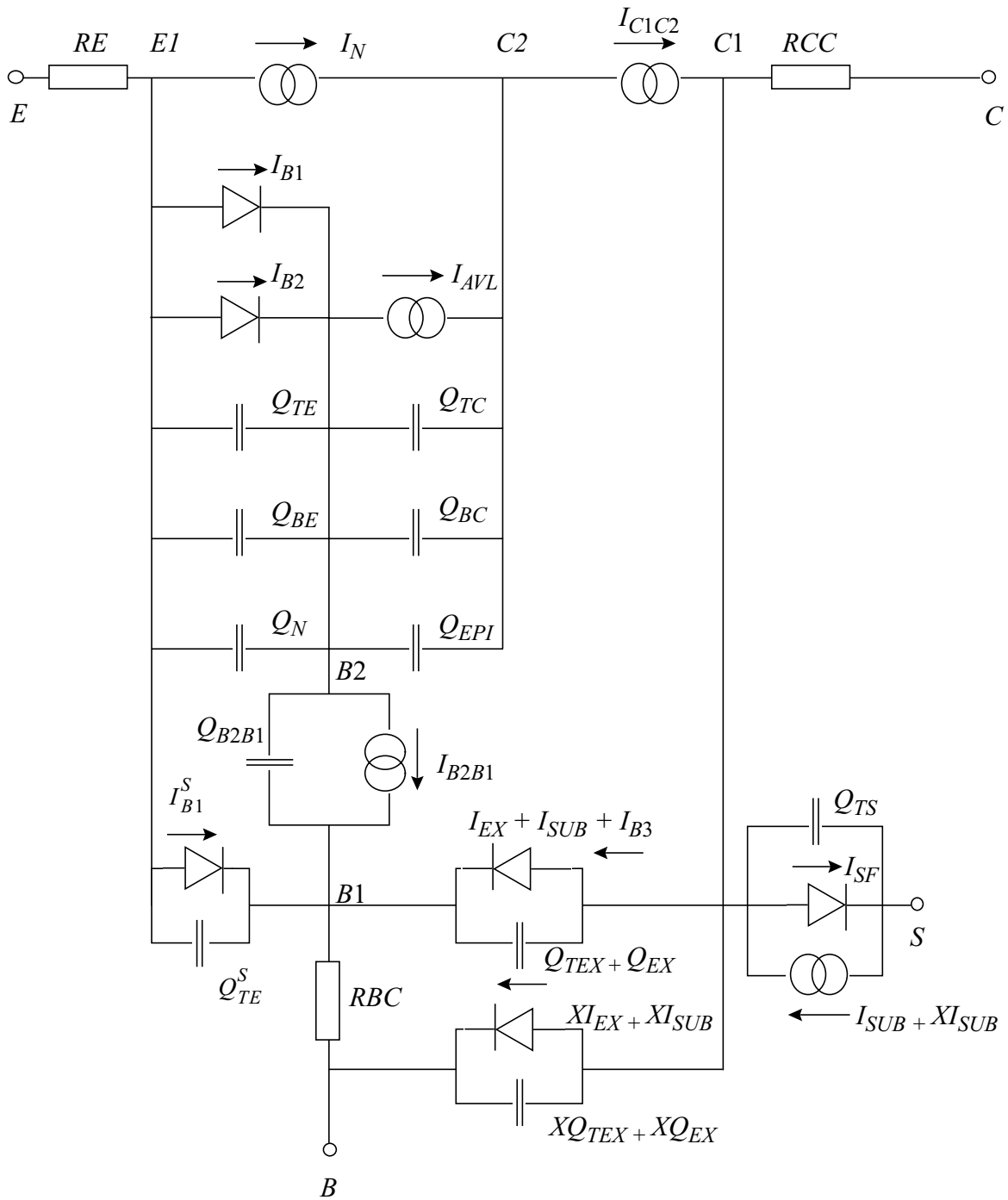


Figure 2: Equivalent circuit for vertical TPS PNP transistor

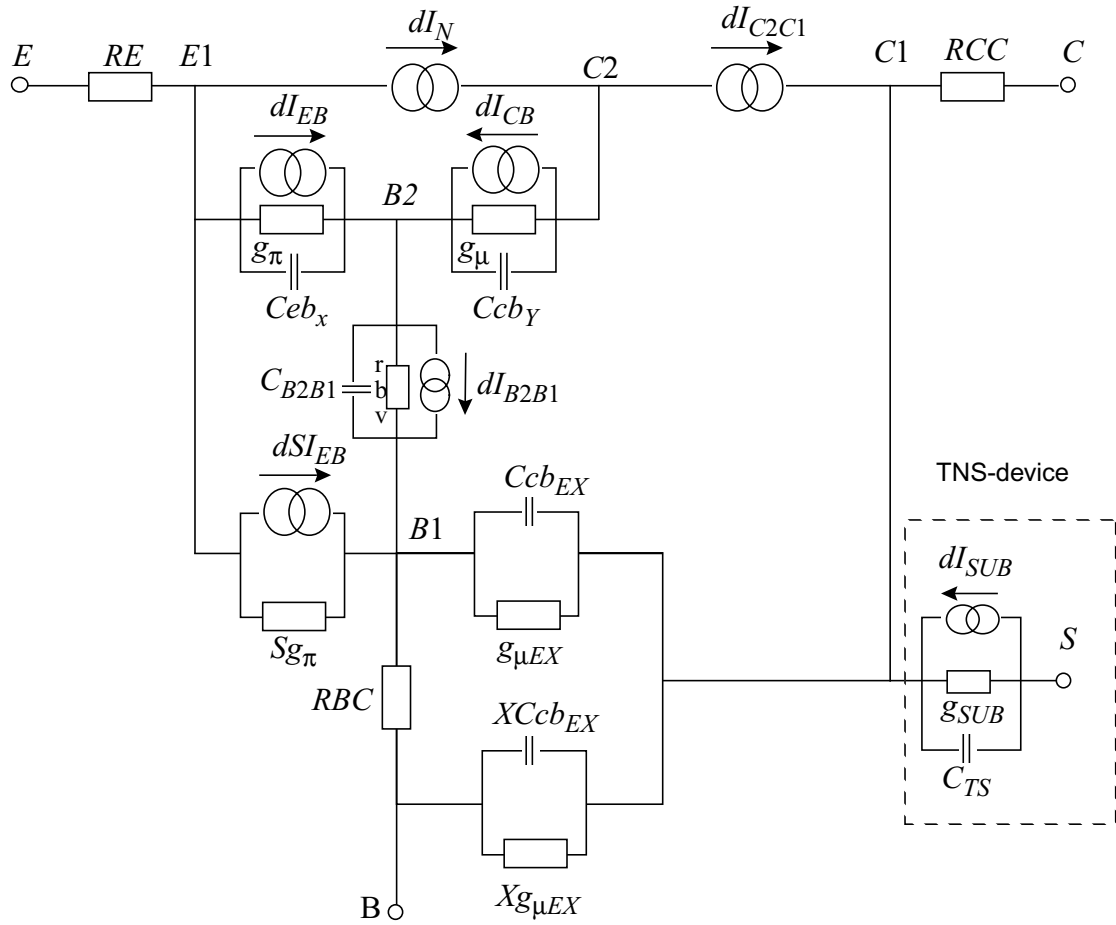


Figure 3: Small signal equivalent circuit for vertical TP/TPS PNP transistor

Model constants

$$k = 1.3806226 \cdot 10^{-23} \text{JK}^{-1}$$

$$q = 1.6021918 \cdot 10^{-19} \text{C}$$

$$\left(\frac{k}{q}\right) = 0.86171 \cdot 10^{-4} \text{V/K}$$

$$\varepsilon = 1.036 \cdot 10^{-12} \text{C/V} \cdot \text{cm}$$

$$V_{lim} = 8 \cdot 10^6 \text{cm/sec}$$

$$G_{MIN} = 1 \cdot 10^{-13} \text{A/V}$$

$$K = .01$$

$$CK = .1$$

Constants A and B for impact ionization depend on transistor type:

for PNP:

$$A_p = 1.58 \cdot 10^6 \text{cm}^{-1}$$

$$B_p = 2.04 \cdot 10^6 \text{V} \cdot \text{cm}^{-1}$$

The default reference temperature $TREF$ for parameter determination is 25°C.

Temperature effects

The actual simulation temperature is denoted by $TEMP$ (in °C). The temperature at which the parameters are determined is $TREF$ (in °C).

- Conversions to Kelvin

$$T_K = TEMP + DTA + 273.15 \quad (1.1)$$

$$T_{RK} = TREF + 273.15 \quad (1.2)$$

$$T_N = \frac{T_K}{T_{RK}} \quad (1.3)$$

$$T_I = \frac{1}{T_{RK}} - \frac{1}{T_K} \quad (1.4)$$

- Thermal Voltage

$$V_T = \left(\frac{k}{q}\right) \cdot T_K \quad (1.5)$$

- Resistances

$$RBC_T = RBC \cdot T_N^{AEX} \quad (1.6)$$

$$RBV_T = RBV \cdot T_N^{AB} \quad (1.7)$$

$$RCC_T = RCC \cdot T_N^{AC} \quad (1.8)$$

$$RCV_T = RCV \cdot T_N^{AEPI} \quad (1.9)$$

- Depletion capacitance

The junction diffusion voltage and junction capacitance with respect to temperature is:

$$VDE_T = -3 \cdot \left(\frac{k}{q}\right) \cdot T_K \cdot \ln(T_N) + VDE \cdot T_N + (1 - T_N) \cdot VGB \quad (1.10)$$

$$CJE_T = CJE \cdot \left(\frac{VDE}{VDE_T}\right)^{PE} \quad (1.11)$$

Where VDE is the junction diffusion voltage and PE is the grading coefficient.

$$VDC_T = -3 \cdot \left(\frac{k}{q}\right) \cdot T_K \cdot \ln(T_N) + VDC \cdot T_N + (1 - T_N) \cdot VGC \quad (1.12)$$

Where VDC is the junction diffusion voltage.

The collector depletion capacitance is divided in a variable and constant part. The constant part is temperature independent.

$$CJC_T = CJC \cdot \left[(1 - XP) \cdot \left(\frac{VDC}{VDC_T} \right)^{PC} + XP \right] \quad (1.13)$$

$$XP_T = XP \cdot \frac{CJC}{CJC_T} \quad (1.14)$$

Where PC is the grading coefficient.

For the TPS-device:

$$VDS_T = -3 \cdot \left(\frac{k}{q} \right) \cdot T_K \cdot \ln(T_N) + VDS \cdot T_N + (1 - T_N) \cdot VGS \quad (1.15)$$

$$CJS_T = CJS \cdot \left(\frac{VDS}{VDS_T} \right)^{PS} \quad (1.16)$$

Where VDS is the junction diffusion voltage and PS is the grading coefficient.

- Base charge

$$QE_T = (1 - XCJE) \cdot \frac{CJE_T \cdot VDE_T}{1 - PE} \quad (1.17)$$

$$QB0_T = g_{i_T} \cdot Q_{imp} - QE_T - XCJC \cdot CJC_T \cdot VDC_T \left(\frac{1 - XP_T}{1 - PC} + XP_T \right)$$

with:

$$g_{i_T} = \frac{-R_T + \sqrt{R_T^2 + 8 \cdot R_T}}{4} \quad (\text{for } R_T \rightarrow \infty: g_{i_T} = 1)$$

$$R_T = (T_K)^{1.5} \cdot \frac{4.82 \cdot 10^{15}}{NA} \cdot \exp\left[-\left(\frac{q}{k}\right) \cdot \frac{VI}{T_K}\right]$$

$$Q_{imp} = \frac{1}{g_i} \cdot \left\{ QB0 + QE + XCJC \cdot CJC \cdot VDC \left(\frac{1 - XP}{1 - PC} + XP \right) \right\}$$

$$QE = (1 - XCJE) \cdot \frac{CJE \cdot VDE}{1 - PE}$$

$$g_i = \frac{-R + \sqrt{R^2 + 8 \cdot R}}{4} \quad (\text{for } R \rightarrow \infty: g_i = 1)$$

$$R = (T_{RK})^{1.5} \cdot \frac{4.82 \cdot 10^{15}}{NA} \cdot \exp\left[-\left(\frac{q}{k}\right) \cdot \frac{VI}{T_{RK}}\right]$$

Q_{imp} has to be calculated with all parameter values at the reference temperature.

- Current gain

$$BF_T = BF \cdot T_N^{(0.03 - 1.5 \cdot AB)} \cdot \exp\left[\left(\frac{q}{k}\right) \cdot (V_{GB} - V_{GE}) \cdot T_I\right] \quad (1.18)$$

The parameter BRI is assumed to be temperature independent.

- Currents and Voltages

$$IS_T = IS \cdot T_N^{(3.8 - 1.5 \cdot AB)} \cdot \exp\left[\left(\frac{q}{k}\right) \cdot V_{GB} \cdot T_I\right] \quad (1.19)$$

$$IBF_T = IBF \cdot T_N^2 \cdot \exp\left[\left(\frac{q}{k}\right) \cdot \left(\frac{VGJ}{2}\right) \cdot T_I\right] \quad (1.20)$$

$$VLF_T = VLF - ER \cdot (T_K - T_{RK}) \quad (1.21)$$

$$IK_T = IK \cdot T_N^{(1 - AB)} \quad (1.22)$$

$$IBR_T = IBR \cdot T_N^2 \cdot \exp\left[\left(\frac{q}{k}\right) \cdot \left(\frac{VGC}{2}\right) \cdot T_I\right] \quad (1.23)$$

$$VLR_T = VLR - ER \cdot (T_K - T_{RK}) \quad (1.24)$$

For the TPS-device:

The temperature dependence of ISS and IKS is given by AS and VGS .

AS equals AC for a closed buried layer (BN) and AS equals $AEPI$ for an open buried layer.

$$ISS_T = ISS \cdot T_N^{(3.5 + AS)} \cdot \exp\left[\left(\frac{q}{k}\right) \cdot VGS \cdot T_I\right] \quad (1.25)$$

$$IKS_T = IKS \cdot T_N^{(1 - AS)} \quad (1.26)$$

- Transit times

$$MTAU_T = \frac{MTAU}{MTAU - T_N \cdot (MTAU - 1)} \quad (1.27)$$

$$TAUNE_T = TAUNE \cdot T_N^{(1 + AB)} \cdot \left\{ \frac{T_{RK}^{1/MTAU}}{T_K^{1/MTAU_T}} \right\}^3 \quad (1.28)$$

$$\exp\left[\left(\frac{q}{k}\right) \cdot \left\{ VGJ \cdot T_I + VGB \cdot \left(\frac{1}{MTAU_T \cdot T_K} - \frac{1}{MTAU_T \cdot T_{RK}} \right) \right\}\right]$$

- Avalanche parameter

$$\Delta T_1 = TREF - 25$$

$$\Delta T_2 = TEMP + DTA - 25$$

$$AVL_T = AVL \cdot \frac{1 + 7.2 \cdot 10^{-4} \cdot \Delta T_2 - 1.6 \cdot 10^{-6} \cdot (\Delta T_2)^2}{1 + 7.2 \cdot 10^{-4} \cdot \Delta T_1 - 1.6 \cdot 10^{-6} \cdot (\Delta T_1)^2} \cdot \frac{CJC}{CJC_T} \quad (1.29)$$

Temperature related parameters

For the TP device: V_{GE} , V_{GB} , V_{GJ} , V_{GC} , AB , AEX , AC , $AEPI$, VI , NA and ER .

For the TPS device: V_{GE} , V_{GB} , V_{GJ} , V_{GS} , V_{GC} , AB , AEX , AC , $AEPI$, AS , VI , NA and ER .

Parameter dependent constants

$$ah0 = 2 \cdot \left[\frac{1 - \exp(-\eta)}{\eta} \right] \quad (1.30)$$

$$ahb = ah0 \quad (1.31)$$

$$alb = \exp(-\eta) \quad (1.32)$$

$$bh0 = \frac{1}{ah0} \quad (1.33)$$

$$bhb = bh0 \quad (1.34)$$

$$bl0 = \frac{\eta - (1 - alb)}{(1 - alb)^2} \quad (1.35)$$

$$blb = \frac{1 - (\eta + 1) \cdot alb}{(1 - alb)^2} \quad (1.36)$$

Model parameter: ETA (η)

Description of currents

- Ideal forward current and reverse current.

$$I_F = IS_T \cdot \exp\left(\frac{V_{E1B2}}{V_T}\right) \quad (1.37)$$

$$I_R = IS_T \cdot \exp\left(\frac{V_{C2B2}}{V_T}\right) \quad (1.38)$$

Model parameter: IS

- The main current I_N

The Moll-Ross formulation is used to take into account high injection in the base. To avoid dividing by zero the depletion charge term is modified.

$$q_0 = 1 + \frac{Q_{TE} + Q_{TC}}{QB0_T} \quad (1.39)$$

$$q_1 = \frac{q_0 + \sqrt{q_0^2 + K}}{2}$$

$$q_2 = \frac{Q_{BE} + Q_{BC}}{QB0_T} \quad (1.40)$$

$$I_N = \frac{I_F - I_R}{q_1 + q_2} \quad (1.41)$$

Model parameter: $QB0$

3 Note

The depletion charges Q_{TE} , Q_{TC} , Q_{BE} and Q_{BC} are given by Eqs. 1.83, 1.87, 1.96 and 1.99 respectively.

- Forward base currents.

The total ideal base current is separated into a bulk and sidewall component. The bulk component depends on voltage V_{E1B2} and the sidewall component on voltage V_{E1B1} . The separation is given by parameter $XIBI$.

Bulk component:

$$I_{B1} = (1 - XIBI) \cdot \frac{IS_T}{BF_T} \cdot \left\{ \exp\left(\frac{V_{E1B2}}{V_T}\right) - 1 \right\} \quad (1.42)$$

Sidewall component:

$$I_{B1}^S = XIBI \cdot \frac{IS_T}{BF_T} \cdot \left\{ \exp\left(\frac{V_{E1B1}}{V_T}\right) - 1 \right\} \quad (1.43)$$

The non-ideal base current is given by:

$$I_{B2} = IBF_T \cdot \left\{ \frac{\exp\left(\frac{V_{E1B2}}{V_T}\right) - 1}{\exp\left(\frac{V_{E1B2}}{2 \cdot V_T}\right) + \exp\left(\frac{V_{LFT}}{2 \cdot V_T}\right)} \right\} + G_{MIN} \cdot V_{E1B2} \quad (1.44)$$

Model parameters: IS , BF , $XIBI$, IBF and VLF

- Reverse base currents.

In TP/TPS-level-503 the non-ideal reverse current is part of the basic Mextram model.

$$I_{B3} = IBR_T \cdot \left\{ \frac{\exp\left(\frac{V_{C1B1}}{V_T}\right) - 1}{\exp\left(\frac{V_{C1B1}}{2 \cdot V_T}\right) + \exp\left(\frac{V_{LRT}}{2 \cdot V_T}\right)} \right\} + G_{MIN} \cdot V_{C1B1} \quad (1.45)$$

For the TPS-device:

The substrate current (holes injected from base to substrate), including high injection is given by:

$$I_{SUB} = \frac{2 \cdot ISS_T \cdot \left\{ \exp\left(\frac{V_{C1B1}}{V_T}\right) - 1 \right\}}{1 + \sqrt{1 + 4 \cdot \frac{IS_T}{IKS_T} \cdot \left\{ \exp\left(\frac{V_{C1B1}}{V_T}\right) \right\}}} \quad (1.46)$$

Note that the knee of the substrate current is projected on the emitter current, therefore in the square root: $4 \cdot IS_T / IKS_T$

$$I_{SF} = ISS_T \cdot \left\{ \exp\left(\frac{V_{C1S}}{V_T}\right) - 1 \right\} \quad (1.47)$$

The extrinsic base current (electrons injected from collector to extrinsic base) is given by:

$$g_1 = \frac{4 \cdot IS_T \cdot (aho)^2 \cdot \exp\left(\frac{V_{C1B1}}{V_T}\right)}{IK_T \cdot (alb)^2}$$

$$n_{BEX} = alb \cdot \frac{g_1}{2 \cdot [1 + \sqrt{1 + g_1}]} \quad (1.48)$$

$$g_{EX} = \frac{1}{BRI}$$

$$I_{EX} = g_{EX} \cdot \left\{ \frac{alb + n_{BEX}}{ahb + n_{BEX}} \cdot \frac{IK_T}{ahb} \cdot n_{BEX} - IS_T \right\}$$

Model parameters:

For the TP-device: $IBR, VLR, BRI, IS, ETA, IK$

For the TPS-device: $IBR, VLR, ISS, IKS, BRI, IS, ETA, IK$

- Weak avalanche current

if $I_N \leq 0$ or $I_{CAP} \leq 0$ then $I_{AVL} = 0$

The current I_{CAP} is defined by Eqn. 1.85 or 1.86 respectively.

At low current level the internal junction voltage is;

$$V_J = -V_{C1B2} - I_{CAP} \cdot RCV_T \quad (1.49)$$

If $V_j > -0.9 \cdot VDC_T$ then

$$WD_{EPI} = \frac{AVL_T}{B_p \cdot XP_T} \quad (1.50)$$

$$F_C^{-1} = (1 - XP_T) \cdot \frac{\left(1 - \frac{I_{CAP}}{IHC}\right)^{MC}}{\left(1 + \frac{V_J}{VDC_T}\right)^{PC}} + XP_T \quad (1.51)$$

$$W_D = F_C \cdot \frac{AVL_T}{B_p} \quad (1.52)$$

$$dEWD = F_C \cdot VDC_T \cdot \frac{B_p}{AVL_T} \quad (1.53)$$

$$E_0 = \frac{V_J + VDC_T}{W_D} + dEWD \cdot \left(1 - \frac{I_{CAP}}{I_{HC}}\right) + \frac{I_{CAP} \cdot RCV_T}{WD_{EPI}} \quad (1.54)$$

$$E_1 = \frac{V_J + VDC_T}{W_D} + \frac{I_{CAP} \cdot RCV_T}{WD_{EPI}} \quad (1.55)$$

If $EXAVL = 0$ then $E_M = E_0$

The generation of avalanche current increases at high current levels. This is taken into account when flag $EXAVL=1$.

If $EXAVL = 1$ then

$$\frac{X_I}{W_{EPI}} = \frac{E_C}{I_{C2C1} \cdot RCV_T} \quad (1.56)$$

$$SH_W = 1 + 2 \cdot SFH \cdot \left(1 + 2 \cdot \frac{X_I}{W_{EPI}}\right) \quad (1.57)$$

$$E_2 = \frac{-V_{C1B2} + VDC_T}{W_D \cdot \left(1 - \frac{X_I}{2 \cdot W_{EPI}}\right)^2} - dEWD \cdot \left(1 - \frac{X_I}{W_{EPI}}\right) \cdot \left(EFI - \frac{I_N}{I_{HC} \cdot SH_W}\right) \quad (1.58)$$

$$E_M = E_0 + \frac{E_2 - E_0 + \sqrt{(E_2 - E_0)^2 + CK \cdot I_{CAP} / I_{HC} \cdot E_1^2}}{2}$$

E_C and I_{C2C1} are given by Eqs. 1.67, 1.80 or 1.81 respectively.

The intersection point X_D and the avalanche current become;

$$X_D = \frac{E_M \cdot W_D}{2 \cdot (E_M - E_1)} \quad (1.59)$$

$$G_{EM} = \frac{A_p}{B_p} \cdot E_M \cdot X_D \cdot \left\{ \exp\left(\frac{-B_p}{E_M}\right) - \exp\left(\frac{-B_p}{E_M} \cdot \left(1 + \frac{W_D}{X_D}\right)\right) \right\} \quad (1.60)$$

$$G_{MAX} = \frac{V_T}{I_N \cdot (RBC_T + RB2)} + \frac{q_1 + q_2}{BF_T} + \frac{RE}{RBC_T + RB2} \quad (1.61)$$

$$I_{AVL} = I_N \cdot \frac{G_{EM} \cdot G_{MAX}}{G_{EM} \cdot (1 + G_{MAX}) + G_{MAX}} \quad (1.62)$$

If $V_j \leq -0.9 \cdot VDC_T$ then $I_{AVL}=0$

Model parameters: AVL , EFI , XP , MC , PC , VDC , RCV , IHC , SFH

3 Note

The variable intrinsic base resistance $RB2$ and the base charge terms q_1 and q_2 are given by Eqs. 1.63, 1.39 and 1.40 respectively.

- Series resistances:

emitter: $RE = \text{constant}$

collector: $RCC_T = \text{constant}$

base: $RBC_T = \text{constant}$

- Variable base resistance

The variable part of the base resistance is modulated by the base charges and takes into account the base current crowding:

$$RB2 = \frac{3 \cdot RBV_T}{q_1 + q_2} \quad (1.63)$$

$$I_{B1B2} = \frac{2 \cdot V_T}{RB2} \cdot \left\{ \exp\left(\frac{V_{B2B1}}{V_T}\right) - 1 \right\} + \frac{V_{B2B1}}{RB2} \quad (1.64)$$

The base charge terms q_1 and q_2 are given by Eqs. 1.39 and 1.40 respectively.

Model parameter: RBV

- Variable collector resistance.

This model of the epilayer resistance takes into account:

- The decrease in resistance due to carriers injected from the base if only the internal base-collector junction is forward biased (quasi-saturation) and if both the internal and external base-collector junction are forward biased (reverse mode of operation).
- Ohmic current flow at low current densities.
- Space charge limited current flow at high current densities.
- Current spreading in the epilayer.

The epilayer current is computed by solving a cubic equation.

$$K_0 = \sqrt{1 + 4 \cdot \exp[(V_{C2B2} - V_{DC_T})/V_T]} \quad (1.65)$$

$$K_W = \sqrt{1 + 4 \cdot \exp[(V_{C1B2} - V_{DC_T})/V_T]} \quad (1.66)$$

$$E_C = V_T \cdot \left[K_0 - K_W - \ln\left(\frac{K_0 + 1}{K_W + 1}\right) \right] \quad (1.67)$$

If $V_{C2B2} - V_{C1B2} > 0$ (forward mode) then

$$S_F = \frac{2 \cdot SFH}{1 + SFH} \quad (1.68)$$

$$V = \frac{V_{C2B2} - V_{C1B2}}{IHC \cdot RCV_T} \quad (1.69)$$

$$E = \frac{E_C}{IHC \cdot RCV_T} \quad (1.70)$$

$$R = \frac{RCV_T}{SCRCV} \quad (1.71)$$

$$A_2 = -2 \cdot E - \frac{V + R \cdot V^2 + E}{1 + V} \quad (1.72)$$

$$A_1 = \frac{E^2 \cdot (3 + V) + 2 \cdot E \cdot V - S_F \cdot E \cdot R \cdot V^2}{1 + V} \quad (1.73)$$

$$A_0 = -\frac{E^2 \cdot (E + V)}{1 + V} \quad (1.74)$$

$$q = A_1/3 - A_2^2/9 \quad (1.75)$$

$$r = (A_1 \cdot A_2 - 3 \cdot A_0)/6 - A_2^3/27 \quad (1.76)$$

$$s = \sqrt{q^3 + r^2} \quad (1.77)$$

$$s_1 = (r + s)^{1/3} \quad (1.78)$$

$$s_2 = (r - s)^{1/3} \quad (1.79)$$

$$I_{C2C1} = I_{HC} \cdot (s_1 + s_2 - A_2/3) \quad (1.80)$$

The argument of the square root of Eqn. 1.77 may become negative. Then s , s_1 and s_2 are complex. The magnitude of the imaginary part of s_1 and s_2 are equal and differ in sign.

If $V_{C2B2} - V_{C1B2} \leq 0$ (reverse mode) then

$$I_{C2C1} = \frac{E_C + V_{C2B2} - V_{C1B2}}{RCV_T} \quad (1.81)$$

Model Parameters: IHC , RCV , $SCRCV$, SFH , VDC

Description of charges

- Emitter depletion charge Q_{TE}

The total base-emitter depletion charge depends on V_{E1B2} :

$$Q_{TE}^{tot} = \frac{CJE_T \cdot VDE_T \cdot (1 + K)}{1 - PE + K} \cdot \left[1 - \frac{(1 + K)^{\left(\frac{PE}{2}\right)} \cdot \left(1 - \frac{V_{E1B2}}{VDE_T}\right)}{\left\{ \left(1 - \frac{V_{E1B2}}{VDE_T}\right)^2 + K \right\}^{\left(\frac{PE}{2}\right)}} \right] \quad (1.82)$$

The total base-emitter depletion capacitance is separated into a bulk and sidewall component. The bulk component is located between node $E1$ and node $B2$ and the sidewall component between nodes $B1$ and $E1$ (see Figure 1).

$$Q_{TE} = (1 - XCJE) \cdot Q_{TE}^{tot} \quad (1.83)$$

$$Q_{TE}^s = XCJE \cdot Q_{TE}^{tot} \quad (1.84)$$

Model parameters : CJE , VDE , PE , $XCJE$

- Intrinsic collector depletion charge Q_{TC1}

If $V_{C2B2} - V_{C1B2} > 0$ then

$$I_{CAP} = \frac{IHC \cdot (V_{C2B2} - V_{C1B2})}{V_{C2B2} - V_{C1B2} + IHC \cdot RCV_T} \quad (1.85)$$

$$CKI = CK + \frac{I_{CAP}}{IHC}$$

If $V_{C2B2} - V_{C1B2} \leq 0$ then

$$I_{CAP} = \frac{V_{C2B2} - V_{C1B2}}{RCV_T} \quad (1.86)$$

$$CKI = CK$$

The base-collector depletion charge is divided into a constant part (parameter XP) and a variable part. The constant part represents the finite thickness of the epilayer. The depletion charge is a function of the internal and external base-collector junction voltage.

$$VC_1 = \frac{(1 + CK)^{\left(\frac{PC}{2}\right)} \cdot \left(1 - \frac{V_{C2B2}}{VDC_T}\right) \cdot \left(1 - \frac{I_{CAP}}{IHC}\right)^{MC}}{\left\{\left(1 - \frac{V_{C2B2}}{VDC_T}\right)^2 + CKI\right\}^{\left(\frac{PC}{2}\right)}} \quad (1.87)$$

$$VC_V = \frac{VDC_T \cdot (1 - XP_T) \cdot (1 + CK)}{1 - PC + CK} \cdot (1 - VC_1)$$

$$Q_{TC1} = XCJC \cdot CJC_T \cdot \{VC_V - XP_T \cdot (I_{CAP} \cdot RCV_T - V_{C2B2})\}$$

Parameters: $XCJC$, CJC , VDC , PC , XP , MC , RCV , IHC

- Collector transit time in quasi-saturation ΔQ_{SAT}

The current through the epilayer (Eqn. 1.80) without injection ($E_C=0$) is;

$$V_{C2C1} = V_{C2B2} - V_{C1B2}$$

$$I_{(EC=0)} = \frac{IHC \cdot SCRCV \cdot V_{C2C1} + V_{C2C1}^2}{SCRCV \cdot (IHC \cdot RCV_T + V_{C2C1})}$$

To force the same current I_{C2C1} through the epilayer without injection, we need an epilayer voltage of $V_{(EC=0)}$;

$$B_1 = 0.5 \cdot SCRCV \cdot (I_{C2C1} - IHC)$$

$$B_2 = SCRCV \cdot IHC \cdot RCV_T \cdot I_{C2C1}$$

$$V_{(EC=0)} = B_1 + \sqrt{B_1 \cdot B_1 + B_2}$$

The differential resistance $R_{(EC=0)} = \partial V_{(EC=0)} / \partial I_{C2C1}$ is given by;

$$R_{(EC=0)} = \frac{SCRCV \cdot (V_{(EC=0)} + IHC \cdot RCV_T)^2}{V_{(EC=0)}^2 + 2 \cdot V_{(EC=0)} \cdot IHC \cdot RCV_T + SCRCV \cdot IHC^2 \cdot RCV_T}$$

The collector transit time in quasi-saturation now becomes;

$$\Delta Q_{SAT} = R_{(EC=0)} \cdot \frac{\partial Q_{TC1}}{\partial V_{C2B2}} \cdot (I_{C2C1} - I_{(EC=0)}) \quad (1.88)$$

The total collector depletion and transit time charge is

if $I_{C2C1} > 0$ then

$$Q_{TC} = Q_{TC1} + \Delta Q_{SAT} \quad (1.89)$$

if $I_{C2C1} \leq 0$ then

$$Q_{TC} = Q_{TC1} \quad (1.90)$$

- Extrinsic collector depletion charges Q_{TEX} and XQ_{TEX} .

The extrinsic collector depletion charge is partitioned between nodes B1 and C1 and nodes B and C1 respectively independent of flag *EXMOD*.

$$VTEX_1 = \frac{(1 + CK)^{\left(\frac{PC}{2}\right)} \cdot \left(1 - \frac{V_{C1B1}}{VDC_T}\right)}{\left\{\left(1 - \frac{V_{C1B1}}{VDC_T}\right)^2 + CK\right\}^{\left(\frac{PC}{2}\right)}} \quad (1.91)$$

$$VTEX_V = \frac{VDC_T \cdot (1 - XP_T) \cdot (1 + CK)}{1 - PC + CK} \cdot (1 - VTEX_1)$$

$$Q_{TEX} = (1 - XEXT) \cdot (1 - XCJC) \cdot CJC_T \cdot (VTEX_V + XP_T \cdot V_{C1B1})$$

To the external base node is connected;

$$XVTEX_1 = \frac{(1 + CK)^{\left(\frac{PC}{2}\right)} \cdot \left(1 - \frac{V_{C1B}}{VDC_T}\right)}{\left\{\left(1 - \frac{V_{C1B}}{VDC_T}\right)^2 + CK\right\}^{\left(\frac{PC}{2}\right)}} \quad (1.92)$$

$$XVTEX_V = \frac{VDC_T \cdot (1 - XP_T) \cdot (1 + CK)}{1 - PC + CK} \cdot (1 - XVTEX_1)$$

$$XQ_{TEX} = XEXT \cdot (1 - XCJC) \cdot CJC_T \cdot (XVTEX_V + XP_T \cdot V_{C1B})$$

Model parameters: $XCJC$, CJC , VDC , PC , XP , $XEXT$

For the TPS-device:

- Depletion charge Q_{TS} .

$$Q_{TS} = \frac{CJS_T \cdot VDS_T \cdot (1 + K)}{1 - PS + K} \cdot \left[1 - \frac{(1 + K)^{\left(\frac{PS}{2}\right)} \cdot \left(1 - \frac{V_{C1S}}{VDS_T}\right)}{\left\{\left(1 - \frac{V_{C1S}}{VDS_T}\right)^2 + K\right\}^{\left(\frac{PS}{2}\right)}} \right] \quad (1.93)$$

Model parameters: CJS , VDS and PS

- Stored base charges Q_{BE} and Q_{BC}

$$Q_B = q_1 \cdot QB0_T \quad (1.94)$$

$$f_1 = \frac{4 \cdot IS_T \cdot (aho)^2}{IK_T} \cdot \exp\left(\frac{V_{E1B2}}{V_T}\right) \quad (1.95)$$

$$n_0 = \frac{f_1}{2 \cdot (1 + \sqrt{1 + f_1})}$$

$$Q_{BE} = Q_B \cdot n_0 \cdot \left[\frac{\frac{1}{2} + \left(\frac{aho}{4}\right) + n_0}{\left[\left(\frac{1}{2} + \frac{aho}{4}\right)\right] \cdot \left(\frac{bho}{blo}\right) + n_0} \right] \cdot bho \quad (1.96)$$

$$f_2 = 4 \cdot IS_T \cdot (aho)^2 \cdot \exp\left(\frac{V_{C2B2}}{V_T}\right) / \{IK_T \cdot (alb)^2\} \quad (1.97)$$

$$n_B = alb \cdot \frac{f_2}{2 \cdot (1 + \sqrt{1 + f_2})} \quad (1.98)$$

$$Q_{BC} = Q_B \cdot n_B \cdot \left\{ \frac{alb \cdot blb + n_B}{alb \cdot bhb + n_B} \right\} \cdot bhb \quad (1.99)$$

Model parameters: $QB0$, IK , ETA , IS

- Neutral and emitter charge

$$Q_{N0} = TAUNE_T \cdot IK_T \cdot \left(\frac{IS_T}{IK_T}\right)^{\left(\frac{1}{MTAU_T}\right)} \cdot \sqrt{MTAU_T \cdot (2 - MTAU_T)} \cdot \left\{ \frac{MTAU_T - 1}{2 \cdot (2 - MTAU_T)} \right\}^{\left(1 - \frac{1}{MTAU_T}\right)} \quad (1.100)$$

$$Q_N = Q_{N0} \cdot \left\{ \exp\left(\frac{V_{E1B2}}{V_T \cdot MTAU_T}\right) - 1 \right\} \quad (1.101)$$

Model parameters: $TAUNE$, $MTAU$, IS

- Stored epilayer charge

$|V_{C1B2} - V_{C2B2}| > 1 \cdot 10^{-8}$ then

$$Q_{EPI} = IS_T \cdot QB0_T \cdot \frac{\exp\left(\frac{V_{C2B2}}{V_T}\right) - \exp\left(\frac{V_{C1B2}}{V_T}\right)}{I_{C2C1}} \quad (1.102)$$

The current I_{C2C1} is given by Eqn. 1.80 or 1.81 respectively.

if $|V_{C1B2} - V_{C2B2}| \leq 1 \cdot 10^{-8}$ then

$$p_0 = \frac{2 \cdot \{\exp(V_{C2B2} - VDC_T)/V_T\}}{(1 + K_0)} \quad (1.103)$$

$$p_w = \frac{2 \cdot \{\exp(V_{C1B2} - VDC_T)/V_T\}}{(1 + K_w)} \quad (1.104)$$

$$Q_{EPI} = RCV_T \cdot IS_T \cdot QB0_T \cdot \exp\left(\frac{VDC_T}{V_T}\right) \cdot \frac{p_0 + p_w}{2 \cdot V_T} \quad (1.105)$$

Model parameters: $QB0$, RCV , VDC , IS

- Extrinsic charges

$$g_2 = 4 \cdot \exp\left(\frac{V_{C1B1} - VDC_T}{V_T}\right) \quad (1.106)$$

$$p_{WEX} = \frac{g_2}{2 \cdot (1 + \sqrt{1 + g_2})} \quad (1.107)$$

$$g_3 = \frac{RCV_T \cdot IS_T \cdot \exp\left(\frac{VDC_T}{V_T}\right)}{V_T} \quad (1.108)$$

$$g_4 = \frac{alb \cdot blb + n_{BEX}}{alb \cdot bhb + n_{BEX}} \cdot bhb \quad (1.109)$$

$$Q_{EX} = QB0_T \cdot \left(\frac{1 - XCJC}{XCJC}\right) \cdot (g_3 \cdot p_{WEX} + g_4 \cdot n_{BEX}) \quad (1.110)$$

Model parameters: $QB0$, RCV , VDC , IS , $XCJC$

Extended modeling of the reverse current gain $EXMOD = 1$

- Currents

The base current I_{EX} is redefined

$$I_{EX} = (1 - XEXT) \cdot I_{EX} \quad (1.111)$$

For the TPS-device:

The base current I_{SUB} is redefined:

$$I_{SUB} = (1 - XEXT) \cdot I_{SUB} \quad (1.112)$$

A part $XEXT$ of the base current of the extrinsic transistor is connected to the base terminal;

For the TPS-device:

$$XIM_{SUB} = XEXT \cdot \frac{2 \cdot ISS_T \cdot \left\{ \exp\left(\frac{V_{C1B}}{V_T}\right) - 1 \right\}}{1 + \sqrt{1 + 4 \cdot \frac{IS_T}{IKS_T} \left\{ \exp\left(\frac{V_{C1B}}{V_T}\right) \right\}}} \quad (1.113)$$

$$Xg_1 = \frac{4 \cdot IS_T \cdot (aho)^2 \cdot \exp\left(\frac{V_{C1B}}{V_T}\right)}{IK_T \cdot (alb)^2} \quad (1.114)$$

$$Xn_{BEX} = alb \cdot \frac{Xg_1}{2 \cdot [1 + \sqrt{1 + Xg_1}]} \quad (1.115)$$

$$\zeta IM_{EX} = XEXT \cdot g_{EX} \cdot \left(\frac{alb + Xn_{BEX}}{ahb + Xn_{BEX}} \cdot \frac{IK_T}{ahb} \cdot Xn_{BEX} - IS_T \right) \quad (1.116)$$

To improve convergency behaviour the conductivity of branch c1-b is limited to $1/RCC_T$.

For the TP-device:

$$V_{EX} = V_T \cdot \left\{ \ln \left(\frac{V_T}{XEXT \cdot (IS_T \cdot g_{EX}) \cdot RCC_T} \right) + 2 \right\} \quad (1.117)$$

For the TPS-device:

$$V_{EX} = V_T \cdot \left\{ \ln \left(\frac{V_T}{XEXT \cdot (IS_T \cdot g_{EX} + ISS_T) \cdot RCC_T} \right) + 2 \right\} \quad (1.118)$$

$$VB_{EX} = \frac{-(V_{EX} - V_{C1B}) + \sqrt{(V_{EX} - V_{C1B})^2 + K}}{2} \quad (1.119)$$

For the TP-device:

$$F_{EX} = \frac{VB_{EX}}{RCC_T \cdot XIM_{EX} + VB_{EX}} \quad (1.120)$$

For the TPS-device:

$$F_{EX} = \frac{VB_{EX}}{RCC_T \cdot (XIM_{EX} + XIM_{SUB}) + VB_{EX}} \quad (1.121)$$

$$XI_{SUB} = F_{EX} \cdot XIM_{SUB} \quad (1.122)$$

$$XI_{EX} = F_{EX} \cdot XIM_{EX} \quad (1.123)$$

- Charges

The charge Q_{EX} is redefined:

$$Q_{EX} = (1 - XEXT) \cdot Q_{EX} \quad (1.124)$$

$$Xg_2 = 4 \cdot \exp\left\{\left(\frac{V_{C1B} - V_{DC_T}}{V_T}\right)\right\} \quad (1.125)$$

$$Xp_{WEX} = \frac{Xg_2}{2 \cdot [1 + \sqrt{1 + Xg_2}]} \quad (1.126)$$

$$Xg_4 = \frac{alb \cdot blb + Xn_{BEX}}{alb \cdot bhb + Xn_{BEX}} \cdot bhb \quad (1.127)$$

$$XQ_{EX} = F_{EX} \cdot XEXT \cdot QB0_T \cdot \frac{1 - XCJC}{XCJC} \cdot \{(g_3 \cdot Xp_{WEX}) + (Xg_4 \cdot Xn_{BEX})\} \quad (1.128)$$

Model parameter: *XEXT*

3 Note

The depletion charges *QTEX* and *XQTEX* are distributed always over the internal and external base node independent of *EXMOD*.

Distributed high frequency effects in the intrinsic base

Distributed high frequency effects are modeled, in first order approximation, both in lateral direction (current crowding) and in vertical direction (excess phase shift). The distributed effects are part of the Mextram model and can be switched on/off with the flag *EXPHI*. The high frequency current crowding is modeled by;

$$C_B = \frac{1}{5} \cdot \left(\frac{\partial Q_{TE}}{\partial V_{E1B2}} + \frac{\partial Q_{BE}}{\partial V_{E1B2}} + \frac{\partial Q_N}{\partial V_{E1B2}} \right) \quad (1.129)$$

$$Q_{B2B1} = C_B \cdot V_{B2B1} \quad (1.130)$$

For simplicity reasons only the forward depletion and diffusion charges are taken into account. The partial derivative of Q_{B2B1} with respect to V_{E1B2} has to be neglected in AC analysis. In transient analysis (if *EXPHI*=1) the convergency behaviour may be improved by approximating this derivative with:

$$\frac{\partial Q_{B2B1}}{\partial V_{E1B2}} = \left(\frac{\partial Q_{BE}}{\partial V_{E1B2}} + \frac{\partial Q_N}{\partial V_{E1B2}} \right) \cdot \left(\frac{V_{B2B1}}{5 \cdot V_T} \right) \quad (1.131)$$

In vertical direction (excess phase shift) base-charge-partitioning is used. For simplicity reasons it is only implemented for the forward base charge (Q_{BE}) and for low level injection. Now Q_{BE} (Eqn. 1.96) and Q_{BC} (Eqn. 1.99) are redefined according to:

$$Q_{BE}' = (1 - q_C) \cdot Q_{BE} \quad (1.132)$$

$$Q_{BC}' = q_C \cdot Q_{BE} + Q_{BC} \quad (1.133)$$

$$q_C = \frac{2 + \eta - (2 - \eta) \cdot \exp(\eta)}{2 - \eta - (1 - \eta) \cdot \exp(\eta) - \exp(-\eta)} \quad (1.134)$$

For $\eta = 0$ the partitioning factor q_C is 1/3.

Noise model

For noise analysis noise current sources are added to the small signal equivalent circuit. In these equations f represents the operation frequency of the transistor and Δf is the bandwidth. When Δf is taken as 1 Hz, a noise density is obtained.

Thermal noise:

- Emitter Resistor

Emitter Resistor Noise

$$\overline{iN_{RE}^2} = \frac{4 \cdot k \cdot T_K}{RE} \cdot \Delta f \quad (1.135)$$

- Base Resistor

$$\overline{iN_{RBC}^2} = \frac{4 \cdot k \cdot T_K}{RBC_T} \cdot \Delta f \quad (1.136)$$

For the variable part of the base resistance a different formula is used, taking into account the effect of current crowding on noise behaviour:

$$\overline{iN_{RBV}^2} = \frac{5.26 \cdot k \cdot T_K}{RB2} \cdot \left\{ 1 + 2 \cdot \exp\left(\frac{V_{B2B1}}{V_T}\right) \right\}^{\left(\frac{3}{4}\right)} \cdot \Delta f \quad (1.137)$$

Base Resistor Noise

$$\overline{iN_{RB}^2} = \overline{iN_{RBV}^2} + \overline{iN_{RBC}^2} \quad (1.138)$$

- Collector Resistor

Collector Resistor Noise

$$\overline{iN_{RCC}^2} = \frac{4 \cdot k \cdot T_K}{RCC_T} \cdot \Delta f \quad (1.139)$$

For the variable part of the base resistance a different formula is used, taking into account the effect of current crowding on noise behaviour:

- Collector Current

Collector current shot noise:

$$\overline{iN_C^2} = 2 \cdot q \cdot |I_N| \cdot \Delta f \quad (1.140)$$

- Base Current

Forward base current shot noise and 1/f noise:

$$\overline{iN_B^2} = \left\{ 2q[|I_{B1}| + |I_{B2}|] + \frac{MULT}{f} \left[KFN \left(\frac{|I_{B2}|}{MULT} \right)^2 + KF \left(\frac{|I_{B1}|}{MULT} \right)^{AF} \right] \right\} \cdot \Delta f \quad (1.141)$$

Emitter-base sidewall current shot noise and 1/f noise:

$$\overline{iN_{BS}^2} = \left\{ 2 \cdot q \cdot |I_{B1}^S| + \frac{MULT}{f} \cdot KF \cdot \left(\frac{|I_{B1}^S|}{MULT} \right)^{AF} \right\} \cdot \Delta f \quad (1.142)$$

Reverse base current shot noise and 1/f noise:

$$\overline{iN_{B3}^2} = \left\{ 2 \cdot q \cdot |I_{B3}| + \frac{MULT}{f} \cdot KF \cdot \left(\frac{|I_{B3}|}{MULT} \right)^{AF} \right\} \cdot \Delta f \quad (1.143)$$

Base Current Shot Noise

$$\overline{iN_{RB}^2} = \overline{iN_B^2} + \overline{iN_{BS}^2} + \overline{iN_{B3}^2} \quad (1.144)$$

- Extrinsic Current

Extrinsic current shot noise and 1/f noise:

$$\overline{iN_{IEX}^2} = \left\{ 2 \cdot q \cdot |I_{EX}| + \frac{KF}{f} \cdot \left(\frac{|I_{EX}|}{MULT} \right)^{AF} \cdot MULT \right\} \cdot \Delta f \quad (1.145)$$

If *EXMOD* = TRUE we also have:

$$\overline{iN_{XIEX}^2} = \left\{ 2 \cdot q \cdot |XI_{EX}| + \frac{KF}{f} \cdot \left(\frac{|XI_{EX}|}{MULT} \right)^{AF} \cdot MULT \right\} \cdot \Delta f \quad (1.146)$$

Extrinsic Current Shot Noise

$$\overline{iN_{EX}^2} = \overline{iN_{IEX}^2} + \overline{iN_{XIE}^2} \quad (1.147)$$

(1.148)

A Hyp functions

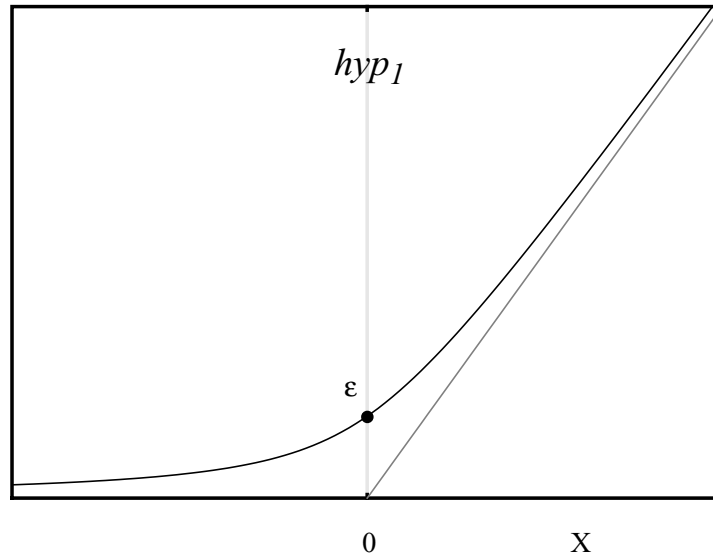


Figure 86: $hyp_1(x;\epsilon) = \frac{1}{2} \cdot (x + \sqrt{x^2 + 4 \cdot \epsilon^2})$

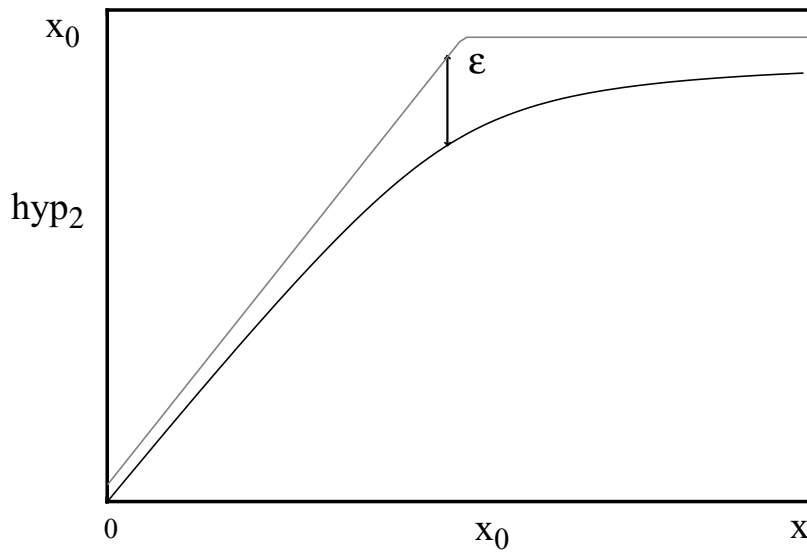


Figure 87: $hyp_2(x;x_0;\epsilon) = x - hyp_1(x - x_0;\epsilon)$

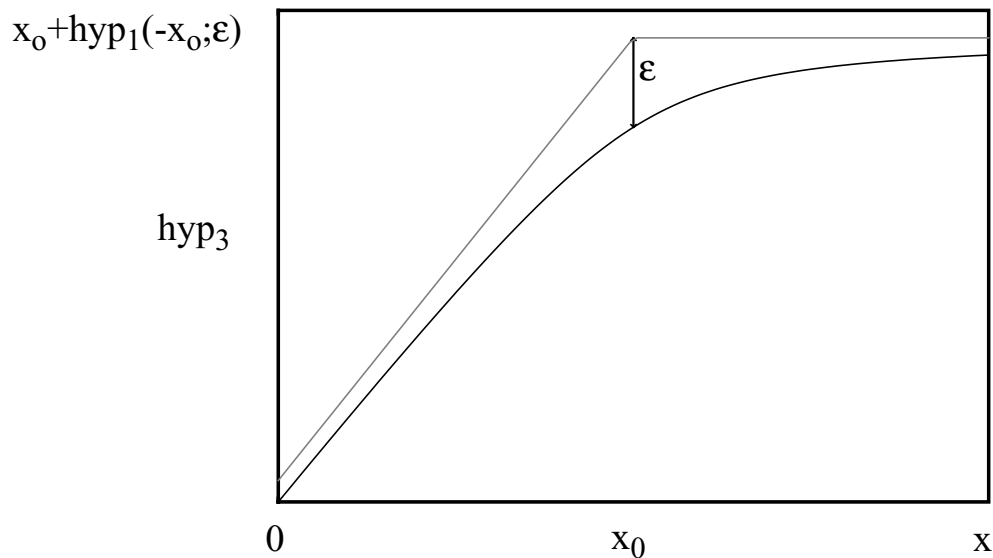


Figure 88: $hyp_3(x; x_0; \epsilon) = hyp_2(x; x_0; \epsilon) - hyp_2(0; x_0; \epsilon)$ for $\epsilon = \epsilon(x_0)$

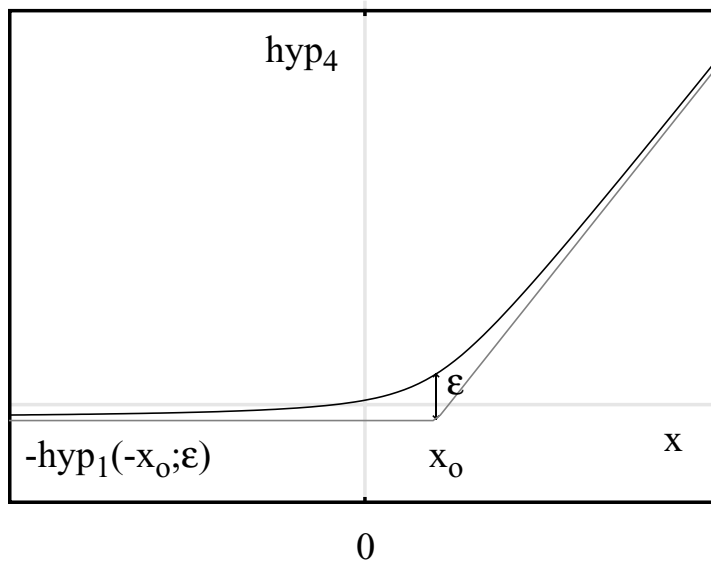


Figure 89: $hyp_4(x; x_0; \epsilon) = hyp_1(x - x_0; \epsilon) - hyp_1(-x_0; \epsilon)$

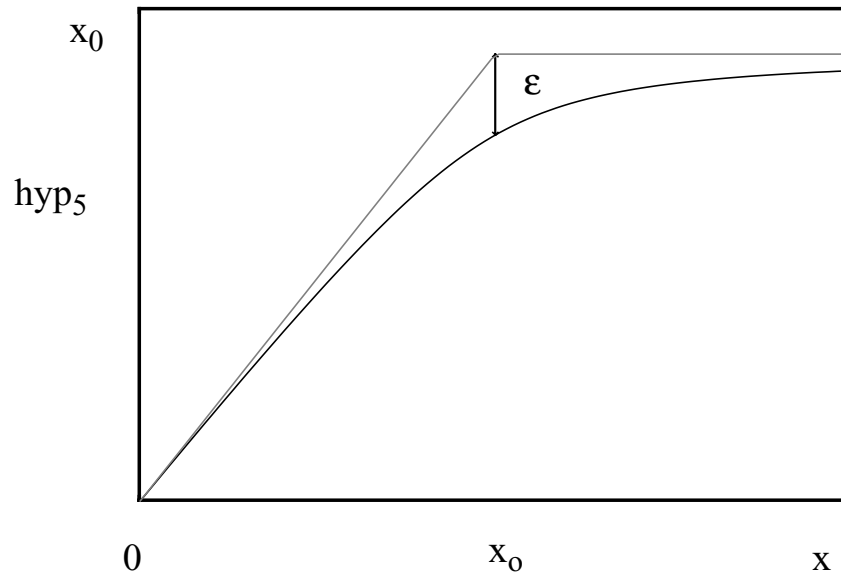


Figure 90: $hyp_5(x; x_0; \varepsilon) = x_0 - hyp_1\left(x_0 - x - \frac{\varepsilon^2}{x_0}, \varepsilon\right)$ for $\varepsilon = \varepsilon(x_0)$

The hypm-function:

$$hypm[x, y; m] = \frac{x \cdot y}{(x^{2 \cdot m} + y^{2 \cdot m})^{1/(2 \cdot m)}} \quad (18.133)$$

B Spectre Specific Information

Imax, Imelt, Jmelt parameters

Introduction

Imax, Imelt and Jmelt are Spectre-specific parameters used to help convergence and to prevent numerical problems. We refer in this text only to the use of Imax model parameter in Spectre with SiMKit devices since the other two parameters, Imelt and Jmelt, are not part of the SiMKit code. For information on Imelt and Jmelt refer to Cadence documentation.

Imax model parameter

Imax is a model parameter present in the following SiMKit models:

- juncap and juncap2
- psp and pspnqs (since they contain juncap models)

In Mextram 504 (bjt504) and Modella (bjt500) SiMKit models, Imax is an internal parameter and its value is set through the adapter via the Spectre-specific parameter Imax.

In models that contain junctions, the junction current can be expressed as:

$$I = I_s \exp\left(\frac{V}{N \cdot \phi_{TD}} - 1\right) \quad (18.134)$$

The exponential formula is used until the junction current reaches a maximum (explosion) current Imax.

$$I_{max} = I_s \exp\left(\frac{V_{expl}}{N \cdot \phi_{TD}} - 1\right) \quad (18.135)$$

The corresponding voltage for which this happens is called Vexpl (explosion voltage). The voltage explosion expression can be derived from (1):

$$V_{expl} = N \cdot \phi_{TD} \log\left(\frac{I_{max}}{I_s}\right) + 1 \quad (18.136)$$

For $V > V_{expl}$ the following linear expression is used for the junction current:

$$I = I_{max} + (V - V_{expl}) \frac{I_s}{N \cdot \phi_{TD}} \exp\left(\frac{V_{expl}}{N \cdot \phi_{TD}}\right) \quad (18.137)$$

The default value of the I_{max} model parameter for SiMKit is 1000A. The default value of I_{max} for Mextram 504 and Modella is 1A. I_{max} should be set to a value which is large enough so it does not affect the extraction procedure.

Region parameter

Region is an Spectre-specific model parameter used as a convergence aid and gives an estimated DC operating region. The possible values of region depend on the model:

- For Bipolar models:
 - subth: Cut-off or sub-threshold mode
 - fwd: Forward
 - rev: Reverse
 - sat: Saturation.
 - off¹
 -
- For MOS models:
 - subth: Cut-off or sub-threshold mode;
 - triode: Triode or linear region;
 - sat: Saturation
 - off¹

For PSP and PSPNQS all regions are allowed, as the PSP(NQS) models both have a MOS part and a juncap (diode). Not all regions are valid for each part, but when e.g. region=forward is set, the initial guesses for the MOS will be set to zero. The same holds for setting a region that is not valid for the JUNCAP.

- For diode models:
 - fwd: Forward
 - rev: Reverse
 - brk: Breakdown
 - off¹

¹.Off is not an electrical region, it just states that the user does not know in what state the device is operating

Model parameters for device reference temperature in Spectre

This text describes the use of the `tnom`, `tref` and `tr` model parameters in Spectre with SiMKit devices to set the device reference temperature.

A Simkit device in Spectre has three model parameter aliases for the model reference temperature, `tnom`, `tref` and `tr`. These three parameters can only be used in a model definition, not as instance parameters.

There is no difference in setting `tnom`, `tref` or `tr`. All three parameters have exactly the same effect. The following three lines are therefore completely equivalent:

```
model nmos11020 mos11020 type=n tnom=30
model nmos11020 mos11020 type=n tref=30
model nmos11020 mos11020 type=n tr=30
```

All three lines set the reference temperature for the `mos11020` device to 30 C.

Specifying combinations of `tnom`, `tref` and `tr` in the model definition has no use, only the value of the last parameter in the model definition will be used. E.g.:

```
model nmos11020 mos11020 type=n tnom=30 tref=34
```

will result in the reference temperature for the `mos11020` device being set to 34 C, `tnom=30` will be overridden by `tref=34` which comes after it.

When there is no reference temperature set in the model definition (so no `tnom`, `tref` or `tr` is set), the reference temperature of the model will be set to the value of `tnom` in the options statement in the Spectre input file. So setting:

```
options1 options tnom=23 gmin=1e-15 reltol=1e-12 \
  vabstol=1e-12 iabstol=1e-16
model nmos11020 mos11020 type=n
```

will set the reference temperature of the `mos11020` device to 23 C.

When no `tnom` is specified in the options statement and no reference temperature is set in the model definition, the default reference temperature is set to 27 C.

So the lines:

```
options1 options gmin=1e-15 reltol=1e-12 vabstol=1e-12 \
  iabstol=1e-16
model nmos11020 mos11020 type=n
```

will set the reference temperature of the mos11020 device to 27 C.

The default reference temperature set in the SiMKit device itself is in the Spectre simulator never used. It will always be overwritten by either the default "options tnom", an explicitly set option tnom or by a tnom, tref or tr parameter in the model definition.

